



Doc. No.: 2336-195

PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :  
NA, Jeong Seok et al. : Confirmation No. 9972  
U.S. Patent Application No. 10/622,466 : Group Art Unit: 2812  
Filed: July 21, 2003 : Examiner: Stephen Smoot

For: METHOD FOR MANUFACTURING GALLIUM NITRIDE(GaN) BASED SINGLE CRYSTALLINE SUBSTRATE

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- No additional fee is required.  
 Small entity status of this application has been established.  
 Also attached:

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	14	20	0	x \$ 18 =	\$ 0.00
Independent Claims	1	3	0	x \$ 88 =	\$ 0.00
If multiple claims newly presented, add \$290.00					
Fee for extension of time					
<b>TOTAL FEE DUE</b>					<b>\$ 0.00</b>

- A credit card authorization form in the amount of \_\_\_\_\_ is attached
- The Commissioner is hereby authorized to charge payment of any *deficiency* in fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

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Docket No.: 2336-195

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AMENDMENT

COMMISSIONER FOR PATENTS  
P.O. Box 1450  
Alexandria VA 22313-1450

Sir:

The following amendments and remarks are submitted in response to the Official Action dated July 28, 2004.